Supporting Information for

# Ultra-Stable and Durable Piezoelectric Nanogenerator with All-Weather Service Capability based on N-Doped 4H-SiC Nanohole Arrays

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## **Supplementary Figures**



Fig. S1 (a, b) SEM images of NHAs. (c) The diameter distribution of N doped 4H-SiC NHAs



Fig. S2 (a) XRD results of NHAs and their powder. (b) TEM images of NHAs. (c) HRTEM image and (d) SAED patterns of the selected area B in (b)

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**Fig. S3** (a) Full XPS spectrum of NHAs. Fine XPS spectrum of different elements: (b) C 1s; (c) Si 2p; (d) O 1s; (e) N 1s



Fig. S4 PFM amplitude-voltage butterfly curve of 4H-SiC and N doped 4H-SiC

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**Fig. S5** Distribution of D and V of the units with different diameter: (**a**) 20 nm; (**b**) 40 nm; (**c**) 80 nm; (**d**) 100 nm; (**e**) 200 nm



Fig. S6 Density of Isc of PENG based on N doped 4H-SiC NHAs and the blank one

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**Fig. S7** (a)  $V_{oc}$  of PENG under resistive load varies from 1 M $\Omega$  to 100 M $\Omega$ . (b) The tendency of  $V_{oc}$  and power density of PENG under different resistances. (c) The voltage of PENG after bridge rectification. (d) The charging curve of 100  $\mu$ F capacitor



**Fig. S8** Density of  $I_{sc}$  of PENG when stimulated in different ways: (**a**) finger tapping; (**b**) foot striking; (**c**) simulated cantilever beam; (**d**) simulated exhaust emission